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PATENT Attorney Docket No. 401479/Aoyama

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Art Unit: 2855

Examiner: Unassigned

In re Application of:

IZUO et al.

Application No. 10/009,521

Filed: December 11, 2001

For: METHOD AND APPARATUS FOR

RADIATION ASSISTED

ELECTROCHEMICAL ETCHING AND

ETCHED PRODUCT

REQUEST FOR CORRECTED OFFICIAL FILING RECEIPT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

An error has been noted on the Official Filing Receipt in the referenced application, namely, the fourth assignee's name is misspelled. Please issue a Corrected Official Filing Receipt correcting this error as marked in red on the attached copy of the Official Filing Receipt.

Respectfully submitted,

leffrøy Al Wyand, Røg. No. 29,4

LEYDIO, VOIT & MAYER / 700 Thirteenth Street, N.W. Suite 300

Washington, DC 20005-3960 (202) 737-6770 (telephone) (202) 737-6776 (facsimile)

Date Sujut He, 2003



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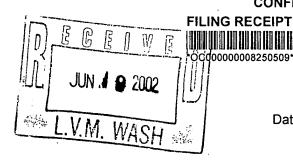
COMMISSIONER FOR PATENTS UNITED STATES PATENT AND TRADEMARK OFFICE WASHINGTON, D.C. 20231

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GRP ART UNIT APPLICATION NUMBER FILING DATE FIL FEE REC'D ATTY.DOCKET.NO **DRAWINGS** TOT CLAIMS IND CLAIMS 10/009,521 12/11/2001 2855 974 401479 12

CONFIRMATION NO. 4369

23548 LEYDIG VOIT & MAYER, LTD 700 THIRTEENTH ST. NW SUITE 300 WASHINGTON, DC 20005-3960



Date Mailed: 06/13/2002

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Applicant(s)

Shinichi Izuo, Tokyo, JAPAN; Hiroshi Ohii. Tokvo. JAPAN: Kazubiko Tsutsumi, Tokyo, JAPAN; Pattrick Jame French, Delft, NETHERLANDS:

Patrick James

Domestic Priority data as claimed by applicant

THIS APPLICATION IS A 371 OF PCT/JP00/03307 05/24/2000

Foreign Applications

Projected Publication Date: Not Applicable, filed prior to November 29,2000

Non-Publication Request: No

Early Publication Request: No

Title

Method and apparatus for radiation assisted electrochemical etching and etched product

Preliminary Class

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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D		DRAWINGS	TOT CLMS	IND CLMS
10/009.521	12/11/2001	1742	1060	401479	12	18	3

CONFIRMATION NO. 4369

CORRECTED FILING RECEIPT

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23548 LEYDIG VOIT & MAYER, LTD 700 THIRTEENTH ST. NW SUITE 300 WASHINGTON, DC 20005-3960

Date Mailed: 11/04/2004

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections, facsimile number 703-746-9195. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

Shinichi Izuo, Tokyo, JAPAN; Hiroshi Ohji, Tokyo, JAPAN; Kazuhiko Tsutsumi, Tokyo, JAPAN; Patrick James French, Delft, NETHERLANDS;

Power of Attorney:

Jeffrey Wyand--29458 John M. Belz--30359 Michael Tobias--32948 Jeremy M. Jay--33587 Joseph Ostroff--39321 Patrick Jewik--40456 Gregory Hunt--41085

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP00/03307 05/24/2000

Foreign Applications

If Required, Foreign Filing License Granted: 11/04/2004

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is US10/009,521

Projected Publication Date: None, application is not eligible for pre-grant publication

Non-Publication Request: No

Early Publication Request: No

Title

METHOD AND APPARATUS FOR RADIATION ASSISTED ELECTROCHEMICAL ETCHING AND ETCHED PRODUCT

Preliminary Class

205

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